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PTO/SB/21 (05-03) Approved for use through 04/30/2003. OMB 0651-0031 U.S. Patent and Trademark Office; U.S. DEPARTMENT OF COMMERCE are required to respond to a collection of information unless it displays a valid OMB control number Paperwork Reduction Act of 1995, no persons **Application Number** 10/669,621 **TRANSMITTAL** Filing Date 2003 September 24, FORM First Named Inventor Mingbing WONG et al Art Unit (to be used for all correspondence after initial filing) 1744 Examiner Name Randall E.CHIN Attorney Docket Number 12553/122 Total Number of Pages in This Submission **ENCLOSURES** (Check all that apply) After Allowance communication to Group Drawing(s) Fee Transmittal Form Appeal Communication to Board Licensing-related Papers of Appeals and Interferences Fee Attached Appeal Communication to Group Petition (Appeal Notice, Brief, Reply Brief) Amendment/Reply Petition to Convert to a Proprietary Information After Final **Provisional Application** Power of Attorney, Revocation Status Letter Change of Correspondence Address Affidavits/declaration(s). Other Enclosure(s) (please Terminal Disclaimer Identify below): Extension of Time Request 1. Certificate of Correction Request for Refund **Express Abandonment Request** 2. Patent 7,059,005 B2 (Changes CD, Number of CD(s) marked in red) Information Disclosure Statement Remarks Certified Copy of Priority Document(s) Certificate Response to Missing Parts/ Incomplete Application NOV 1 5 2006 Response to Missing Parts under 37 CFR 1.52 or 1.53 of Correction SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT Firm Mark D. Yuan (Reg. No. 57,312) Individual name Signature Date 2/0/06 CERTIFICATE OF TRANSMISSION/MAILING I hereby certify that this correspondence is being facsimile transmitted to the USPTO or deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on the date shown below. M/S: Certificate of Correction Branch Typed or printed name Barbara Vance November 6, 2006 Date Signature

This collection of information is required by 37 CFR 1.5. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.14. This collection is estimated to 12 minutes to complete, including gathering, preparing, and submitting the completed application form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, VA 22313-1450. DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

PPLICANTS

Mingbing WONG et al.

SERIAL NO.

10/669,621

FILED

September 24, 2003

PATENT NO.

7,059, 005 B2

ISSUED

June 13, 2006

FOR

POLISH CLEANING APPARATUS AND METHOD IN

MANUFACTURE OF HGA

M/S: CERTIFICATE OF CORRECTION BRANCH Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 Certificate of Mailing

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Date November 6, 2006

Barbara Vance

REQUEST FOR CERTIFICATE OF CORRECTION

Dear Sir:

We have compared the above patent with the application as filed and have found errors in the printing of the patent. We respectfully request that the enclosed Certificate of Correction on Form PTO-1050 be issued correcting the mistakes set forth therein under authority of 35 U.S.C. §254. The exact column and line number where the errors occurred in the patent are listed on the enclosed certificate.

WUY 1 6 2006.

The errors that appear in the patent are typographical errors made by the Patent Office and therefore, no fee is required.

Respectfully submitted,

KENYON & KENYON

Dated: November 6, 2006

By:

Mark D/Yuan

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UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO

7,059,005 B2

DATED

June 13, 2006

INVENTOR(S):

Mingbing WONG et al.

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 1, line 52: "write head" should be --read/write head--

1,0% 1 6 200

MAILING ADDRESS OF SENDER: KENYON & KENYON LLP

Attorney Ref.: 12553/122

PATENT NO. 7,059,005 B2

Date: November 6,2006

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This collection of information is required by 37 CFR 1.322, 1.323, and 1.324. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.14. This collection is estimated to take 1.0 hour to complete, including gathering, preparing, and submitting the completed application form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, VA 22313-1450. DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.



(12) United States Patent

Wong et al.

(10) Patent No.:

US 7,059,005 B2

(45) Date of Patent:

Jun. 13, 2006

(54) POLISH CLEANING APPARATUS AND METHOD IN MANUFACTURE OF HGA

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(HK)

Notice: Subject to any disclaimer, the term of this

patent is extended or adjusted under 35

U.S.C. 154(b) by 253 days.

Appl. No.: 10/669,621 (21)

(22)Filed: Sep. 24, 2003

(65)**Prior Publication Data**

US 2004/0058622 A1 Mar. 25, 2004

Related U.S. Application Data

Division of application No. 09/810.833, filed on Mar. (62)16. 2001, now Pat. No. 6,645,308.

(30)Foreign Application Priority Data

Apr. 13, 2000 (CN) PCT/CN00/00089

(51) Int. Cl. B24B 49/00 (2006.01)G11B 5/41 (2006.01)B08B 11/02

360/128 Field of Classification Search 15/21.1, (58)

15/77, 97.1, 102; 360/128; 451/5 See application file for complete search history.

(2006.01)

U.S. Cl. 15/102; 15/97.1; 451/5;

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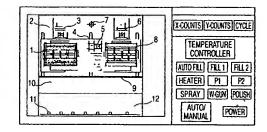
^{*} cited by examiner

Primary Examiner-Randall Chin (74) Attorney, Agent, or Firm-Kenyon & Kenyon

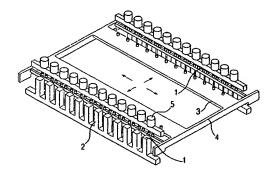
ABSTRACT

A method and apparatus for cleaning the slider air bearing surface of a head gimbal assembly is disclosed. A plurality of carriers may position and hold a plurality of head gimbal assemblies to be polished. A cloth strip may be rubbed against the slider air surface. A movable cylinder unit coupled to the plurality of carriers may move the carriers. A polish tank may provide cleaning solution to the movable cylinder unit. A pump may recirculate the cleaning solution. A filter canister with a filter cartridge may filter the cleaning solution.

7 Claims, 2 Drawing Sheets



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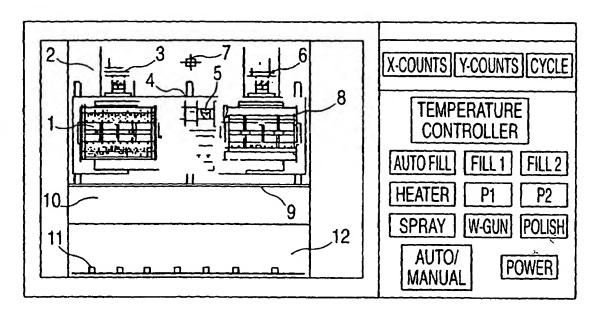


FIG. 1

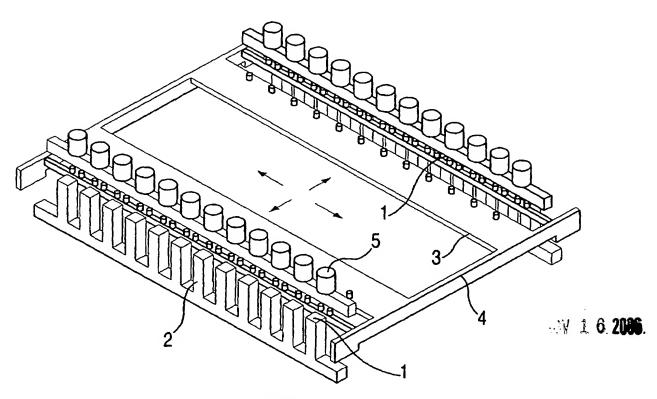


FIG. 2

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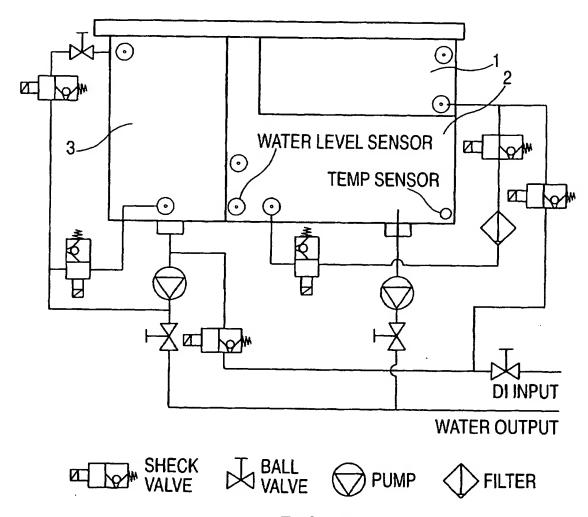


FIG. 3

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POLISH CLEANING APPARATUS AND METHOD IN MANUFACTURE OF HGA

RELATED APPLICATION

This application is a Divisional of patent application Ser. No. 09/810,833 filed on Mar. 16, 2001 and issued as U.S. Pat. No. 6,645,308 on Nov. 11, 2003.

FIELD OF THE INVENTION

The present invention relates generally to a cleaning and polishing apparatus and method used in the disk drive industry. More specifically, the present invention relates to a cleaning and polishing apparatus and method used in the 15 manufacture of a head gimbal assembly.

BACKGROUND OF THE INVENTION

Thin film heads are used for reading or writing data onto 20 a recording layer of a data storage disk. Typically, the head "flies" above the surface of the disk at a very low "altitude". The height of the air gap between the head and the disk is usually measured in fractions of a micron. The low height of the air gap causes an air bearing to be formed.

For a disk that stores data using magnetic effects, the head usually includes a radio frequency coil for transmitting and receiving a magnetic field to write and read in the recording layer. For disks that store data using optical effects, the head may include an objective lens to focus a light beam at the 30recording layer.

Along with the evolution of the disk industry, the surface cleanliness of read-write heads has become one of the most critical concerns. With low-flying heads, dust in the environment is a serious problem. Dust particles can cause 35 catastrophic "head crashes" destroying the head and disk. Also, significant amounts of dust can accumulate on the head to interfere with the magnetic or optical effects. Contaminants may cause a disk driver to malfunction or even fail to spin up.

Classical wash, rinse and dry technology using an aqueous chemical substance and ultrasonic agitation can not provide adequate cleaning efficiency for a head's air bearing surface. More effective contamination removal methods to ensure that components and drives always remain as clean as 45 possible are needed.

U.S. Pat. No. 5,467,238 issued to Neville K. Lee et al. on Nov. 14, 1995, disclosed a cleaning apparatus for cleaning read/write heads used for accessing data stored on a recording disk of a disk drive. The cleaning apparatus had a 50 mounting base positioned adjacent to the disk. The base includes a ratchet mechanism for rotating a cleaning pad mounted thereon. The rotary or linear actuator arm used to position the read/write head activates the ratchet mechanism. The ratchet mechanism rotates the cleaning pad while 55 the actuator unloads the read/write head from the disk. A loading ramp is used to vertically position the write head relative to a cleaning surface of the cleaning pad. This conventional cleaning apparatus is more complicated in structure, lower in efficiency, and is used only after assembly of a disk drive, making it unsuitable for use in the mass production of the heads.

SUMMARY OF THE INVENTION

A new kind of cleaning and polishing apparatus and method for cleaning the heads of a head gimbal assembly to

eliminate contamination of the heads by dusts or particulates is disclosed. In accordance with one aspect of the present invention, a cleaning and polishing apparatus for cleaning a head may have a frame, a plurality of carriers for locating and holding a plurality of HGAs, a plurality of polish fingers under the carriers and fixed on a loading base, a cloth attached to said fingers, and a plurality of press-pins on each of the carriers. The HGAs may have a face and a slider with an air-bearing surface (ABS) to be polished and directed 10 downwards. The cloth may act as a polish medium to provide a plurality of polish surfaces on which the HGAs are polished and cleaned. The press pins press on a HGA's flexure to provide proper friction between the slider ABS and the polish surface.

According to another embodiment, a pneumatic cylinder unit is combined with the carriers. The pneumatic cylinder unit, controlled by a programmable controller, may move the carriers, as well as the plurality of HGAs. The pneumatic cylinder unit may move back and forth in X and Y directions according to a customized program. The solution may be sufficiently agitated by the motion of a cylinder unit to promote dissolution action. Also, a polish tank containing a cleaning solution, may be provided on the top of the frame. The cleaning solution is recirculated through a pump and a filter canister with an effective filter cartridge. The filter canister may filter off the insoluble, suspended contaminants and particles in the solution so that the slider ABS will not be re-contaminated. A thermostatically controlled strip heater may heat the solution to a desired working temperature. The contaminants may be scrubbed off into the solution through solubilization, emulsification, chemical action by a detergent, etc. The temperature, kind, and concentration of the chemical substance of said solution may be selected to achieve maximum cleaning effectiveness. The apparatus and method of the invention is suitable for the removal of dusts, oils, fingerprints, and other organic and inorganic contaminants in the form of both particulate and thin-film.

BRIEF DESCRIPTION OF THE DRAWINGS

The above and other objects and advantages of the present invention will be described by way of preferred embodiments and with reference to the drawings, in which

FIG. 1 is a top view of the polish cleaning apparatus of the present invention:

FIG. 2 is a perspective view of an HGA carrier positioned on polish fingers in the polish cleaning apparatus of the present invention; and

FIG. 3 is a diagram of water circulation of the polish cleaning apparatus.

DETAILED DESCRIPTION

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The head gimbal assembly (HGA) is a kind of precision component in a disk drive. The conventional ultrasonic cleaning can cause mechanical damage under high ultrasonic power, which limits its application, and can not provide an adequate cleaning effect. However, the new polish cleaning technology can effectively clean the head and does not cause side effects for HGA performance. Basically, the polish cleaning can remove all kinds of contaminants such as dust, particles, film, etc. Its removal efficiency can achieve up to 95% for all kinds of contaminants whether it's organic or inorganic, while the classical ultrasonic cleaning does only about 60% for small particles and is not efficient for other kinds of contaminants.

read/write

As shown in FIGS. 1-3, one embodiment of a polishing and cleaning apparatus of the present invention may have polish fingers. HGA carriers, a cylinder motion unit and an immersion polish tank.

In one embodiment of the present invention, the polishing 5 and cleaning method may be a contact-cleaning process using a type of polyester cloth. The polyester cloth has good anti-static properties having less particles or even being particle-free and has good wear durability as a cleaning medium. A pneumatic cylinder unit may bring the HGA 10 being polished and cleaned into the cleaning area. The pneumatic cylinder unit may move back and forth in both X and Y directions on a cloth-strip wrapped onto a set of polish fingers. The slider air bearing surface (ABS) is polished with a much higher cleaning efficiency (nearly 90%), as shown in 15 FIG. 1.

In one embodiment illustrated by FIG. 2, cleaning units 1 and 8 may have two rows of polish fingers 2. On these two rows of polish fingers 2, a kind of anti-static polyester cloth-strip is fixed smoothly by tension force to form a 20 polish cleaning surface. A plurality of HGAs 1 may be positioned on the cleaning surface to be cleaned and polished effectively.

The HGA carriers hold a plurality of HGAs 1. The HGA carriers also position the plurality of HGA 1 by the coordination of the carriers and polish fingers, see FIG. 2. The HGA carriers may have a plurality of cylindrical pressing pins to press on a HGA's flexure. The HGA carriers may move back and forth according to a computer program for substantially simultaneous polishing and cleaning.

In one embodiment, the cylinder motion units may each comprise an X-cylinder 4, 5 and a Y-cylinder 3, 6. The X-cylinder 4, 5 and Y-cylinder 3, 6 move back and forth in X or Y direction, according to a computer program customized in advance, and cause HGA carriers as well as the 35 plurality of HGAs to move in both X and Y directions repeatedly.

In one embodiment illustrated in FIG. 3, the HGA carriers containing the HGAs may be immersed into a polish tank containing a solution so that the HGAs can be cleaned and 40 polished. The tank may have an overflow weir, a pump, and a filter canister. The filter canister may have a 0.2 micron filter cartridge for solution recirculating and filtering. The tank may also have a thermostatically controlled strip heater to heat the solution to a proper working temperature.

The cleaning function may have chemical and physical actions, as well as the polish cleaning. A cloth scrubbing action may be performed first. The moving cloth strip scrubs off contaminants on the dirty slider surface being cleaned.

7. The cleaning truction may have chemical and physical actions may have chemical and physical actions plurality of polymers.

The detergent dissolution action may be performed second. The contaminants scrubbed off may be placed into

solution through solubilization, emulsification, chemical action by a detergent, etc. As in a conventional cleaning process, time, temperature, and kind and concentration of the detergent may be important parameters in achieving maximum cleaning effectiveness. Motion of the cylinder may provide sufficient agitation to promote dissolution action.

The filtration action may be performed third. A filter canister may filter off the insoluble, suspended contaminants and particles in solution in time. Otherwise, they may re-contaminate the products so that the latter must be cleaned again.

While the present invention has been described by way of the preferred embodiments, the foregoing described is in all aspects illustrative, not restrictive. It is obvious to a person skilled in this art that numerous variations and modifications can be devised without departure from the scope of the invention.

What is claimed is:

- 1. A cleaning apparatus comprising:
- a plurality of carriers to position and hold a plurality of head gimbal assemblies each with a slider air bearing surface to be polished:
- a frame to support the plurality of carriers:
- a cloth strip to be rubbed against the slider air bearing surface:
- a movable cylinder unit coupled to the plurality of carriers to move the carriers;
- a polish tank containing cleaning solution to be provided to the movable cylinder unit;
- a pump to recirculate the cleaning solution; and
- a filter canister with a filter cartridge to filter the cleaning
- 2. The cleaning apparatus of claim 1, wherein the polish tank is positioned on top of the frame.
- 3. The cleaning apparatus of claim 1, wherein the solution is a detergent.
- 4. The cleaning apparatus of claim 1, further comprising a thermostatically controlled strip heater to heat the solution.
- 5. The cleaning apparatus of claim 1, further comprising a series of press-pins to press the slider air bearing surface of the head gimbal assemblies into the cloth strip by applying pressure to a flexure of the head gimbal assemblies.
 - 6. The cleaning apparatus of claim 1, further comprising a plurality of polish fingers on which the cloth strip is wrapped.
 - 7. The cleaning apparatus of claim 1, wherein the cylinder unit is pneumatic.